Page 1 Serial No. LIST OF PATENTS AND PUBLICATIONS Attorney Docket: 101215-75 09/998,446 APPLICANT'S INFORMATION Applicant: EDISCLOSURE STATEMENT (Form PTO-1449 Modified) Jörg-Thomas Zettler et al. Filing Date: Group: Nov. 30, 2001 **TBA U.S. PATENT DOCUMENTS** Examiner & Sub **Filing Date** Initial If appropriate **Document Number** Date Name Class Class MIL 4/1995 AA5 4 0 3 4 3 3 P. Morrison, et al. 156 626 AB AC AD ΑE AF AG AH ΑI AJ AK FOREIGN PATENT DOCUMENTS Sub **Translation Document Number** Class Date Country Class Yes No AL 44 19 476 12/1994 Germany AM AN AO AP OTHER PRIOR ART (Including Author, Title, Date, Pertinent Pages, Etc.)

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